



ITW

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.: **10/549,609**

Filing Date: September 20, 2005

Applicant: Tomoko AKAI et al.

Group Art Unit: 4122

Examiner: Margaret Brodie

Title: METHOD FOR PRODUCING HIGH SILICATE GLASS
AND HIGH SILICATE GLASS (as amended)

Atty. Dkt. No.: 12480-000144/US

Customer Service Window
Randolph Building
401 Dulany Street
Alexandria, VA 22314
Mail Stop **Amendment**

June 18, 2009

AMENDMENT UNDER 37 C.F.R. § 1.111

Dear Sir:

In response to the Office Action (hereinafter 'Action') mailed on March 18, 2009, the following amendments and remarks are respectfully submitted in connection with the above-identified patent application.

	Claims remaining after Amendment		Highest number previously paid for		Present extra
Total	19	-	20	=	0
Independent	1	-	3	=	0